

PROPERTIES of Ge, Si, and GaAs at 300 K

Properties	Ge	Si	GaAs
Atoms/cm ³	4.42×10^{22}	5.0×10^{22}	4.42×10^{22}
Atomic weight	72.60	28.09	144.63
Breakdown field (V/cm)	$\sim 10^5$	$\sim 3 \times 10^5$	$\sim 4 \times 10^5$
Crystal structure	Diamond	Diamond	Zincblende
Density (g/cm ³)	5.3267	2.328	5.32
Dielectric constant	16.0	11.9	13.1
Effective density of states in conduction band, N_C (cm ⁻³)	1.04×10^{19}	2.8×10^{19}	4.7×10^{17}
Effective density of states in valence band, N_V (cm ⁻³)	6.0×10^{18}	1.04×10^{19}	7.0×10^{17}
Effective Mass, m^*/m_0 Electrons	$m_l^* = 1.64$ $m_t^* = 0.082$	$m_l^* = 0.98$ $m_t^* = 0.19$	0.067
Effective Mass, m^*/m_0 Holes	$m_{lh}^* = 0.044$ $m_{hh}^* = 0.28$	$m_{lh}^* = 0.16$ $m_{hh}^* = 0.49$	$m_{lh}^* = 0.082$ $m_{hh}^* = 0.45$
Electron affinity, χ (V)	4.0	4.05	4.07
Energy gap (eV) at 300K	0.66	1.12	1.424
Intrinsic carrier concentration (cm ⁻³)	2.4×10^{13}	1.45×10^{10}	1.79×10^6
Intrinsic Debye length (μm)	0.68	24	2250
Intrinsic resistivity ($\Omega\text{-cm}$)	47	2.3×10^5	10^8
Lattice constant (\AA)	5.64613	5.43095	5.6533
Linear coefficient of thermal expansion, $\Delta L/L\Delta T$ ($^\circ\text{C}^{-1}$)	5.8×10^{-6}	2.6×10^{-6}	6.86×10^{-6}
Melting point ($^\circ\text{C}$)	937	1415	1238
Minority carrier lifetime (s)	10^{-3}	2.5×10^{-3}	$\sim 10^{-8}$
Mobility (drift) (cm ² /V-s)	3900 1900	1500 450	8500 400
Optical-phonon energy (eV)	0.037	0.063	0.035
Phonon mean free path λ_0 (\AA)	105	76 (electron) 55 (hole)	58
Specific heat (J/g- $^\circ\text{C}$)	0.31	0.7	0.35
Thermal conductivity at 300 K (W/cm- $^\circ\text{C}$)	0.6	1.5	0.46
Thermal diffusivity (cm ² /s)	0.36	0.9	0.24
Vapor pressure (Pa)	1 at 1330 $^\circ\text{C}$ 10^{-6} at 760 $^\circ\text{C}$	1 at 1650 $^\circ\text{C}$ 10^{-6} at 900 $^\circ\text{C}$	100 at 1050 $^\circ\text{C}$ 1 at 900 $^\circ\text{C}$

Source: Sze, S.M. Physics of Semiconductor Devices, 2nd Ed.